

Notice of References Cited		Application/Control No. 10/553,573	Applicant(s)/Patent Under Reexamination DUSSARRAT ET AL.	
		Examiner Elizabeth Burkhardt	Art Unit 1792	Page 1 of 1

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-2001/0048973	12-2001	SATO et al.	427/255.39
	B	US-			
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	D	US-			
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	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

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	N	JP 06338497	12-1994	Japan	Ishikawa	
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NON-PATENT DOCUMENTS

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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.